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(71) Applicant (for all designated States except US): **KONINKLIJKE PHILIPS ELECTRONICS N.V.** [NL/NL]; Groenewoudseweg 1, NL-5621 BA Eindhoven (NL).

(72) Inventors; and

(75) Inventors/Applicants (for US only): **HELLMIG, Joachim, W.** [DE/NL]; c/o Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL). **MIJIRITSKII, Andrei** [NL/NL]; c/o Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL).

TUKKER, Teunis, W. [NL/NL]; c/o Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL). **STALLINGA, Sjoerd** [NL/NL]; c/o Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL).

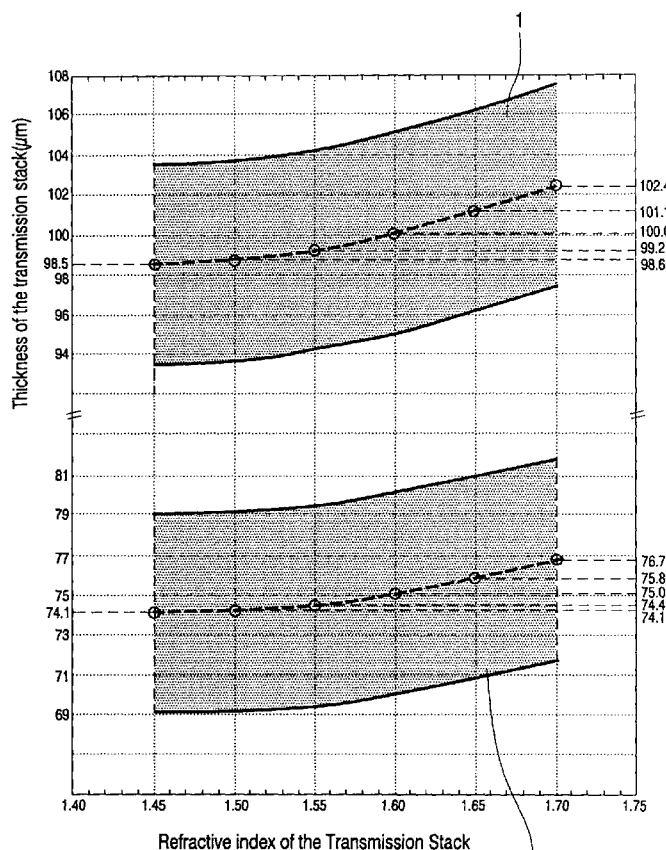
(74) Agent: **DEGUELLE, Wilhelmus, H., G.**; Philips Intellectual Property & Standards, Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL).

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(54) Title: DUAL STACK OPTICAL DATA STORAGE MEDIUM AND USE OF SUCH MEDIUM



(57) Abstract: A dual-stack optical data storage medium (20) is described for read out using a focused radiation beam (29) with a wavelength of 400 - 410 nm and a Numerical Aperture (NA) of 0.84 - 0.86. The medium has a substrate (21) and a first stack of layers named L0 (22) comprising a first information layer and a second stack of layers named L1 (23), comprising a second information layer. A radiation beam (29) transparent spacer layer (24) is present between L0 and L1. A transmission stack named TS0 with a thickness d_{TS0} and an effective refractive index n_{TS0} contains all layers between L0 and an entrance face (26) of the medium (20). A transmission stack named TS1 with a thickness d_{TS1} and an effective refractive index n_{TS1} containing all layers between L1 and the entrance face (26). The spacer layer (24) has a thickness selected from the range 20 - 30 μm, the thickness d_{TS0} in dependence on the refractive index n_{TS0} and the thickness d_{TS1} in dependence on the refractive index n_{TS0} are within a specified area. In this way a reliable read out of both the first and the second information layer of respectively L0 and L1 is achieved.

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